	\	Subclass	ISSUE CLASSIFICATION
69/65328 88/31/88		Class	ISSUE CLA

PATENT NUMBER

U.S. UTILITY Patent Ap	plicatio	n
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O.I.P.E.

PATENT DATE

EXAMINER 13:1.74 ART UNIT APPLICATION NO. CONT/PRIOR CLASS SUBCLASS 09/653281

Kevin Beaman Ronald Weimer

Use of atomic oxidation for fabrication of oxide-nitride-oxide stack for flash memory devices

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ISSUING CLASSIFICATION							
ORIGINAL	CROSS REFERENCE(S)						
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INTERNATIONAL CLASSIFICATION							A
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TERMINAL DISCLAIMER	DRAWINGS			CLAIMS ALLOWED		
	Sheets Drwg.	Figs. Drwg.	Print Fig.	Total Claims	Print Claim for O.G.	
☐ The term of this patent		1		NOTICE OF ALI	LOWANCE MAILED	
subsequent to (date) has been disclaimed.	(Assistant	Examiner)	(Date)			
The term of this patent shall not extend beyond the expiration date of U.S Patent. No.				ISS	UE FEE	
				Amount Due	Date Paid	
	(Primary	Examiner)	(Date)		<u> </u>	
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this patent have been disclaimed.	(Legal Instrum	ients Examiner)	(Date)			
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orm PTO-436A Rev. 6/99)			FILED WITH	: DISK (CRF)	FICHE CD-RO	